

Subclass	Class	ISSUE CLASSIFICATION

PATENT NUMBER

U.S. UTILITY Patent Application

O.I.P.E.

PATENT DATE

02/12/1990
COPIED

APPLICATION NO.	CONT/PRIOR	CLASS	SUBCLASS	ART UNIT	EXAMINER
09/986044	F	A38	710	2763	Hassan Zadeh

Applicant: Osamu Koike

150 345 1763

Title: Plasma etching apparatus with focus ring and plasma etching method

PTO-2040
12/89

ISSUING CLASSIFICATION

GENERAL	OPTICAL	PHOTOGRAPHIC	PRINTING	COMPUTERS
1	2	3	4	5
6	7	8	9	10
11	12	13	14	15
16	17	18	19	20
21	22	23	24	25
26	27	28	29	30
31	32	33	34	35
36	37	38	39	40
41	42	43	44	45
46	47	48	49	50
51	52	53	54	55
56	57	58	59	60
61	62	63	64	65
66	67	68	69	70
71	72	73	74	75
76	77	78	79	80
81	82	83	84	85
86	87	88	89	90
91	92	93	94	95
96	97	98	99	100

TERMINAL DISCLAIMER

The term of old patent
commencing to _____ ()
has been discontinued.

The term of old patent claim
has ended beyond the expiration date
of U.S. Patent No. _____

The terminal _____ months of
this patent have been discontinued.

DRAWINGS

Sheet Drawg. Fig. Drawg. Part Drawg.

(Actual Drawing) (D-)

(Primary Drawing) (D-)

(Actual Drawing) (D-)

(Primary Drawing) (D-)

(Actual Drawing) (D-)

(Primary Drawing) (D-)

EXAMINER'S COMMENTS

Terminal Disclaimers to C.G.C.

NOTICE OF ALLOWANCE MADE

NOTICE OF REJECTION MADE

Amendments 2/20/90

NOTICE OF ALLOWANCE MADE

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